ABSTRACT OF THE DISCLOSURE

A common alignment and shielding apparatus is provided for aligning both a substrate and shadow ring with at least one common guide member. The shadow ring preferably includes a covered recess formed in its lower surface for receiving the common guide member without permitting process gasses to flow therethrough. A method of aligning the substrate and shadow ring is also provided in which the substrate and the shadow ring are both lowered onto the substrate support member and each are adapted to mate with the common guide member.

\\IPL\DOCUMENTS\APPM\2673\PTO\2673.PA.100599.DOC

This Sheet Has Been Replaced

